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8-8-02
Docket No.: 8733.565.00-US
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Yun-Ho Jung

Application No.: 10/025,907

Group Art Unit: 1754

Filed: December 26, 2001

Examiner: Not Yet Assigned

For: APPARATUS AND METHOD OF
CRYSTALLIZING AMORPHOUS SILICON

REQUEST FOR CORRECTED FILING RECEIPT

Office of Initial Patent Examination Customer Service Center
Commissioner for Patents
Washington, DC 20231

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TC 1700

Dear Sir:

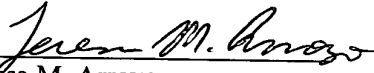
Applicant hereby requests that a corrected Filing Receipt be issued in the above-identified patent application. The official Filing Receipt received by Applicant, a copy of which is attached hereto, has an error in

Applicant(s): Yun-Ho Jung, Seoul, JAPAN should be corrected to Yun-Ho Jung, Seoul, KOREA.

Applicant additionally requests that all pertinent U.S. Patent and Trademark Office records relating to the subject application be changed to reflect this correction.

Dated: May 8, 2002

Respectfully submitted,

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UNITED STATES PATENT AND TRADEMARK OFFICE

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APPLICATION NUMBER	FILING DATE	GRP ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO.	DRAWINGS	TOT CLAIMS	IND CLAIMS
10/025,907	12/26/2001	1754	740	8733.565.00	5	14	3

CONFIRMATION NO. 7489

FILING RECEIPT



OC000000007441383

RGR

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Date Mailed: 02/07/2002

Receipt is acknowledged of this nonprovisional Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Customer Service Center. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

Applicant(s)

Yun-Ho Jung, Seoul, JAPAN;

Domestic Priority data as claimed by applicant

Foreign Applications

REPUBLIC OF KOREA 2000-83763 12/28/2000

If Required, Foreign Filing License Granted 02/07/2002

Projected Publication Date: 07/04/2002

Non-Publication Request: No

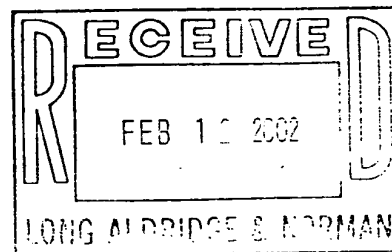
Early Publication Request: No

Title

Apparatus and method of crystallizing amorphous silicon

Preliminary Class

023



LGR

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